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CONTENTS

* Phase Transitions in Ge-Sb-Te Alloys Induced by Ion Irradiations. . .	.2701
Stefania Privitera, Antonio M. Mio, Julia Benke, Christoph Persch, Emanuele Smecca, Alessandra Alberti, and Emanuele Rimini	
Al_{1-x}Sc_xN Thin Film Structures for Pyroelectric Sensing Applications2711
V. Vasilyev, J. Cetnar, B. Claffin, G. Grzybowski, K. Leedy, N. Limberopoulos, D. Look, and S. Tetlak	
Effect of Surface Treatment on the Mode I Debonding of Interface Between Silica and Nylon62717
Saeid Arabnejad, Sergei Manzhos, and VPW Shim	
Study of Flexoelectricity in Graphene Composite Structures2723
Mohamed Serry and Mahmoud A. Sakr	
Effect of Surface Cleaning on Contact Resistivity of Amorphous GeCu₂Te₃ to a W Electrode2731
S. Shindo, Y. Sutou, J. Koike, Y. Saito, and Y.-H. Song	
Comparison of Vanadium Oxide Thin Films Prepared Using Femtosecond and Nanosecond Pulsed Laser Deposition2737
Ying Deng, Anthony Pelton, and R.A. Mayanovic	
The Role of Photo-striction in Tailoring the Nano-scale Phase Changes in Amorphous Selenium Thin Films2743
S. Gayathri, G. Sreevidya Varma, and S. Asokan	

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